Fundamental studies of molecular depth profiling and 3D imaging using Langmuir–Blodgett films as a model

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1. Introduction

The recent development of cluster projectiles has opened new opportunities for materials characterization by SIMS. In particular, depth profiling of molecular species has become possible, which has proved successful experiments on many organic and biological systems [1–5]. This success is mainly attributed to the enhanced sputter yields and lower damage accumulation of cluster bombardment, especially for the C60+ projectile [6,7]. Recently, the concept of three-dimensionally (3D) characterizing the sample has also emerged as a result of the combination of molecular depth profiling and SIMS imaging. The capability of 3D imaging to acquire chemical information as a function of depth provides unique and valuable insight of biological functions and mechanisms [8,9].

At this point, there are still many unknown fundamental issues that need to be understood in order to further develop molecular depth profiling and 3D imaging. One of the important points is to determine the depth resolution and the degree of interface mixing, especially for organic–organic interfaces. The depth resolution can be affected by surface roughness, differential sputtering, and parameters associated with the primary projectile. A reproducible and robust platform with minimal intrinsic chemical mixing between the layers is necessary. LB films are such a model system since they are known to have well-defined layered structures and sharp interfaces between the layers [2,10,11]. Here, we report molecular depth profiling and 3D imaging results using this model system. The LB films were characterized by SIMS and a C60+ probe as a function of depth which facilitated quantitative measurement of the interface width. Furthermore, the LB films were imaged as a function of depth. The reconstruction of the SIMS images correctly represented the original chemical structure of the film. It also provided useful information about interface mixing and edge effects during sputtering.

2. Experimental

The following materials were used without further purification: AA, barium chloride, potassium hydrogen carbonate, and copper(II) chloride (all purchased in powder from Sigma–Aldrich Co., St. Louis, MO), DMPA (Avanti Polar Lipids, Inc., Alabaster, AL), methanol, and chloroform. The water used was purified by a Nanopure Diamond Life Science Ultrapure Water System (Barnstead International Inc., Dubuque, IA). The details of LB film preparation have been described elsewhere [12]. The LB films were formed on a hydrophilic silicon wafer or Au-patterned silicon substrate. For patterned substrates, the silicon wafer was first...
covered by TEM grids fixed by copper tape, which allowed the Au to be deposited onto the bare silicon area. After deposition, metal grids were removed, leaving an Au-patterned silicon substrate. The Au bars were about 100 nm higher than the Si area as measured by a profilometer. The topography was retained after LB film deposition since the LB films formed on both the silicon and Au area. A KLA-Tencor Nanopics 2100 atomic force profilometer (AFP) was used to measure the surface topography and crater depth.

The depth profiling and 3D imaging were performed in a home-built ToF-SIMS instrument equipped with a 40-keV C\textsubscript{60}\textsuperscript{+} ion source (Ionoptika; Southampton, UK). The details of this instrument have been described elsewhere [5]. For depth profiling, the samples were sputtered by the C\textsubscript{60}\textsuperscript{+} beam in dc mode followed by the acquisition of mass spectra from inside the sputtered region with 25% of the erosion area using the C\textsubscript{60}\textsuperscript{+} projectile at an ion fluence of 10\textsuperscript{10} cm\textsuperscript{-2}. The 3D imaging experiments were also performed by alternating between sputter cycles and data acquisition cycles, but the imaging field-of-view was the same size as the sputter area.

3. Results and discussion

The LB film (LB20-4) depth profiled by the C\textsubscript{60}\textsuperscript{+} ion beam consists of 23 layers of AA, 22 layers of DMPA, 20 layers of AA, and 20 layers of DMPA, from bottom to top. The thickness of each chemical block is shown in Fig. 1(a). The depth profile experiments of LB20-4 were performed at both room temperature (RT) and liquid nitrogen temperature (LN\textsubscript{2}T). The characteristic peaks for both molecules are observed in the mass spectra, at \( m/z = 463 \) for AA and \( m/z = 525 \) for DMPA. The integrated intensities of these two peaks as well as the Si signal are plotted against the C\textsubscript{60}\textsuperscript{+} fluence (Fig. 1). Both profiles successfully resolve the chemical variation in the film which is displayed as the alternation of the two signals. The initial increase of \( m/z = 525 \) most probably is due to surface contamination. After the film is removed, the Si signal increases while the AA and DMPA signals go to a minimum value. The most significant difference between the two profiles is the signal intensity of the bottom two chemical blocks, which drops by about 50% in the RT profile yet retains the same level as the top blocks in the LN\textsubscript{2}T profile. Damage accumulation appears to be less severe at low temperature. A possible reason for this effect is that thermal energy created from ion bombardment is quenched at lower temperature, creating less chemical degradation. Interestingly, as is also seen in Fig. 1, the sputter rate is larger at lower temperature, an effect not previously observed. A possible explanation for this result is that the LB film rigidity increases after being cooled, making it a better target for keeping the deposited energy near the surface.

The depth profiling of LB20-4 shows that it is possible to acquire chemical information from buried organic layers. More importantly, it provides a system to quantify the organic–organic interface width. To establish this width, it is necessary to convert the scale of fluence to depth. As shown in Fig. 2(a), the AA and DMPA signals are linearly correlated with each other until the profile reaches the Si region (except the initial contamination region). The two intercepts of the linear fit represent the maximum values that can be obtained in the mass spectra for the two signals. The sputter rate is calculated according to the following equation:

\[
R = R_{AA} \left( \frac{S_{AA,observed}}{S_{AA,max}} \right) + R_{DMPA} \left( \frac{S_{DMPA,observed}}{S_{DMPA,max}} \right)
\]

where \( R_{AA} \) and \( R_{DMPA} \) are the sputter rate of pure AA and DMPA LB films. By multiplying the sputter rate with the sputter time at each point, the depth scale can be obtained.

Fig. 1. (a) Schematic drawing of the LB20-4 with red, green, and blue representing AA, DMPA, and silicon respectively; (b) depth profile of LB20-4 at room temperature; (c) depth profile of LB20-4 at cryogenic temperature. (For interpretation of the references to color in this figure legend, the reader is referred to the web version of the article.)

Fig. 2. (a) Correlation plot of two peak intensities, \( m/z = 463 \) (\( S_{AA} \)) and \( m/z = 525 \) (\( S_{DMPA} \)). The red line represents the linear fit. (b) Depth profile of LB20-4 with the calculated depth scale. (For interpretation of the references to color in this figure legend, the reader is referred to the web version of the article.)
The sputter rates of the LB films on both materials are about the same.

The chemical structure rebuilt from the SIMS depth profile images are shown in Fig. 3. This model experiment suggests that 3D imaging on a laterally inhomogeneous substrate will be possible.

4. Conclusion

By examining chemically alternating LB films as a model system, we have shown that molecular depth profiling of organic–organic multilayers is possible with a C\textsubscript{60}\textsuperscript{+} projectile, especially at LN\textsubscript{T}. The interface width is slightly larger than those measured for organic–inorganic interfaces. The structure rebuilt from the SIMS images shows interface mixing to a certain level. The AFP measurements show that the topography of the material is retained after C\textsubscript{60}\textsuperscript{+} sputtering.

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References


Fig. 3. (a) Schematic drawing of LB20-6 and the DMPA blocks are represented by green, AA blocks are represented by red and Si in blue and (b) the chemical structure rebuilt from the SIMS depth profile images with green showing the DMPA signal, red showing the AA signal, and blue showing Si signal. (For interpretation of the references to color in this figure legend, the reader is referred to the web version of the article.)